

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION OF

HILL et al.

Appln. No.: 09/890,570

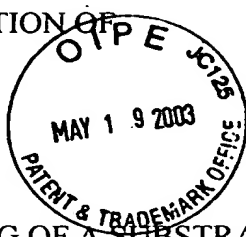
Filed: September 25, 2001

Title: PARTIAL IMAGING OF A SUBSTRATE WITH SUPERIMPOSED LAYERS

Confirmation No.: 4578

Group Art Unit: 4578

Examiner: J. Lorengo



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AMENDMENT

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5/23/03

Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

Sir:

This Amendment responds to the Office Action dated December 18, 2002. This response is timely in view of the attached petition for a two month extension and the fact that the extended due date of May 18, 2003 fell on a Sunday.

Please amend the above identified application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

24. (Amended) A method of imaging an imperforate substrate on a substantially uniform imaging surface of said substrate so as to provide said substrate with a print pattern, said print pattern comprising at least two superimposed layers of marking material and being defined by means of 1) said substrate having at least one of said at least two layers of marking material on first portions of said substrate and 2) said substrate being devoid of both of said at least two layers of marking material on other portions of said substrate, and said at least two superimposed layers of marking material having at least one length of common boundary within said print pattern, said method including applying a base layer to said imaging surface of said substrate, applying at least two initial, continuous, superimposed layers of said marking material onto said base layer, and removing portions of said initial, continuous, superimposed layers of said marking material from said base layer by means of a force